Proton Tolerance of a Third-Generation, 0.12 μm 185 GHz SiGe HBT Technology

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35-Word Abstract

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Oral Presentation Preferred STUDENT PAPER Proton Tolerance of Third-Generation, 0.12 µm 185 GHz SiGe HBTs

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Abstract—We present the first results on the impact of proton irradiation on the dc and ac characteristics of third-generation, 0.12 μ m 185 GHz SiGe HBTs. Comparisons with prior technology generations are used to investigate the damage mechanisms, as well as assess how the structural changes needed to enhance performance between second and third generation technology couple to the observed proton response. The results demonstrate that SiGe HBT technologies can successfully maintain their multi-Mrad total dose hardness, without intentional hardening, even when vertically-scaled in order to achieve unprecedented levels of performance.

I. INTRODUCTION

Bandgap-engineered SiGe HBTs are receiving increasing attention for terrestrial communications IC applications, because they enable a dramatic improvement in transistor-level performance while simultaneously maintaining strict compatibility with conventional low-cost, high-integration level, high-volume Si CMOS manufacturing [1]. SiGe HBT technologies with 50 GHz (first-generation) and 120 GHz (second-generation) peak cutoff frequency are currently in commercial production world-wide from multiple sources, and are being deployed in both the commercial and government sectors. SiGe HBT technology has also generated significant recent interest in the space community, because it offers substantial (multi-Mrad) total dose hardness without any (costly) radiation hardening (SEU tolerance is still under active investigation).

It is logical to wonder (and often asked) what the upper limit is on achievable frequency response in using epitaxial SiGe alloys to engineer SiGe HBTs. The recent announcement of a third-generation SiGe HBT technology with 200 GHz peak cutoff frequency [2] pushed this upper bound considerably higher than previously believed possible. While it might be argued that 200 GHz is not needed to support most IC applications (which are clustered currently in the 1-40 GHz range, such extreme levels of performance afford a much broader circuit design space, where, for instance, a designer might choose to reduce the frequency response in order to realize dramatic power savings (10x reduction in bias current in this case over second-generation tech-

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nology operating at 120 GHz), as indicated in Figure 1. Third-generation SiGe HBTs are in fact quite competitive now with best-of-breed commercial InP HBTs, and clearly out-perform such devices when thermal effects are also considered [1].

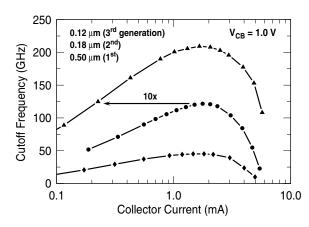


Fig. 1. Measured cut-off frequency as a function of bias current for three SiGe technology generations.

This advance in the SiGe state-of-the-art to 200 GHz performance was only achieved by radically altering the structure of previous SiGe HBT design points. The third-generation SiGe HBT technology used in the present investigation (IBM's 8HP) technology) employs a novel, reduced thermal cycle, "raised extrinsic base" structure, and utilizes conventional deep and shallow trench isolation, an in-situ doped polysilicon emitter, and an unconditionally stable, 25% peak Ge, C-doped, graded UHV/CVD epitaxial SiGe base (Figure 2) [2]. The device structure has been scaled laterally to 0.12 μ m emitter stripe width in order to minimize base resistance and thus improve the frequency response and noise characteristics. Such a raised extrinsic base structure facilitates the elimination of any out-diffusion of the extrinsic base, thereby significantly lowering the collectorbase junction capacitance. From a radiation tolerance perspective, however, the EB spacer and the shallow trench isolation (STI) of the new structure are both fundamentally different than that found in first and second generation (IBM 5HP and 7HP) technology, and the composite films and processing/thermal cycles are significantly altered, raising a potential question as to the overall radiation tolerance of the new device structure. This question is particularly relevant given that the overall processing thermal cycles have been significantly reduced, thus raising questions on the overall robustness of the oxide interfaces, prime damage points in a radiation environment. In this work, we report the first results on the proton tolerance of a third-generation SiGe HBT technology, and compare it with prior SiGe technology generations in order to investigate the basic damage mecha-

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nisms.

II. EXPERIMENT

The third-generation SiGe HBT technology (8HP) examined in this work has a 0.12 μ m emitter stripe width and 185 GHz peak f_T (this was off a different run than that reported in [2], but is essentially the same technology, with a slightly different vertical profile). Two earlier SiGe HBT technology generations were also measured in order to assess the impact of vertical scaling, lateral scaling, and structural changes on the radiation response, and included: a 0.50μ m 50 GHz f_T SiGe HBT (5HP) and a 0.20μ m 120 GHz f_T SiGe HBT (7HP). In the case of 7HP SiGe technology, the effects of radiation on the ac performance are reported here for the first time.

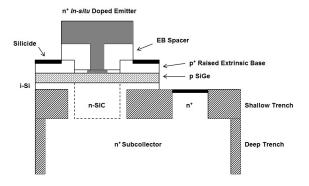


Fig. 2. Schematic cross-section of the 185 GHz SiGe HBT.

The samples were irradiated with 62.5 MeV protons at the Crocker Nuclear Laboratory at the University of California at Davis. The dosimetry measurements used a five-foil secondary emission monitor calibrated against a Faraday cup. The radiation source (Ta scattering foils) located several meters upstream of the target establish a beam spatial uniformity of about 15% over a 2.0 cm radius circular area. Beam currents from about 5 pA to 50 nA allow testing with proton fluxes from 1×10^6 to 1×10^{11} proton/cm²sec. The dosimetry system has been previously described[3] [4], and is accurate to about 10%. At a proton fluence of 1×10^{12} p/cm², the measured equivalent gamma dose was approximately 136 krad(Si). The SiGe HBTs were irradiated with all terminals grounded for the dc measurements and with all terminals floating for the ac measurements at proton fluences ranging from 1.0×10^{12} p/cm² to 5.0×10^{13} p/cm². We have previously shown that SiGe HBTs are not sensitive to applied bias during irradiation. The samples were measured at room temperature with an Agilent 4155 Semiconductor Parameter Analyzer (dc) and an Agilent 8510C Vector Network Analyzer (ac) using the techniques discussed in [6].

III. dc Results

The resultant 8HP forward-mode Gummel characteristics are shown in Figure 3 as a function of proton fluence, and reveal a remarkably minor degradation in the base current at multi-Mrad equivalent gamma dose. As has been previously discussed [5], this base current degradation is physically the result of proton-induced G/R center recombination leakage current, physically

located at the emitter-base spacer at the emitter periphery.

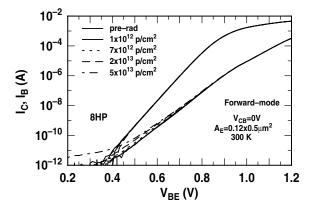


Fig. 3. Forward-mode Gummel characteristics of the 8HP SiGe HBT.

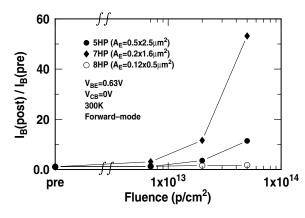


Fig. 4. Comparison of the normalized base current in forward-mode as a function of proton fluence for the 5HP, 7HP, and 8HP SiGe HBT technology generations.

A comparison of the normalized base current degradation of the 8HP transistor to that of the first (5HP) and second (7HP) generation SiGe devices shows that 8HP experiences significantly smaller radiation-induced damage than the earlier technology generations (Figure 4). This result is a pleasant surprise, and would appear to be in direct contradiction with results on SiGe HBT scaling presented in 2002 [5], in which vertical and lateral device scaling generally degraded the forward-mode proton response. It should be noted, however, that this result can be easily misinterpreted, since the base current ideality of the preradiation device influences the final base current change. That is, in the case of 8HP, there is clearly a pre-existing G/R center dominated base current leakage component, as evidenced by the non-ideal base current slope (about 120 mV/decade, consistent with classical G/R leakage). For the 5HP and 7HP devices, however, the starting base currents are significantly more ideal, and hence even a small absolute degradation of the base current due to proton exposure will produce a larger damage ratio in those devices. In effect, the 8HP base current damage is still present, but effectively "hidden" beneath the pre-radiation, non-ideal base leakage component. We would expect that as the 8HP technology matures, that its pre-radiation, non-ideal base current will become more ideal, facilitating a more meaningful comparison with 5HP and 7HP devices, and this will be quantified at a later

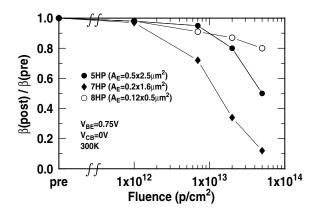


Fig. 5. Comparison of the normalized current gain as a function of proton fluence for the 5HP, 7HP, and 8HP SiGe HBT technology generations.

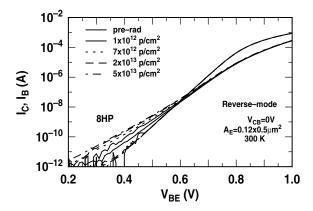


Fig. 6. Inverse-mode Gummel characteristics of the 8HP SiGe HBT.

point. Nevertheless, at the low-end of practical circuit operating currents (e.g., $I_C = 1.0 \mu A$), the change in the current gain (β) for the 8HP device is less than 20% at $5 \times 10^{13} p/cm^2$, significantly better than either 5HP or 7HP (Figure 5). This is clearly very good news, and speaks well of the inherent tolerance of the various potentially sensitive interfaces in the modified, lowthermal budget, 8HP device structure (e.g., EB spacer, and STI edge). Measurements of the inverse-mode Gummel characteristics (emitter and collector swapped, which effectively samples the physical collector-base junction) indicate again, that while the pre-radiation base current is less ideal than perhaps desired, the proton-induced change to the inverse-mode base current is minor at best, consistent with the fact that the STI is very thin in this technology (much less than 5HP, but similar to 7HP) and thus has less impact on the collector-base junction characteristics. This is significant, given that, unlike for the 5HP and 7HP devices, the overall thermal cycle of the 8HP process is substantially reduced, and hence no out-diffusion of the extrinsic base is available to "cover" the exposured corners of the STI with high doping, effectively containing any proton-induced damage. This result suggests that this "raised extrinsic base" 8HP structure should continue to enjoy substantial proton tolerance even as the technology is further scaled for even higher performance, as has in fact been very recently reported (a 350 GHz peak f_T SiGe HBT [7]).

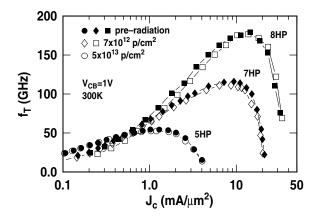


Fig. 7. Pre-radiation and post-radiation cut-off frequency versus collector current density for 8HP, 7HP, and 5HP SiGe HBTs.

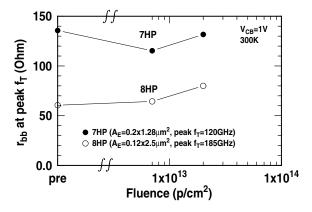


Fig. 8. Dynamic base resistance dependence on proton fluence.

IV. ac RESULTS

The transistor scattering parameters (S-parameters) were fully characterized to 26 GHz, from which the cut-off frequency f_T was extracted at each bias current point. The pre- and post-radiation cut-off frequency versus collector current density for the 8HP devices are shown in Figure 7, together with comparisons to the 7HP (at $7 \times 10^{12} p/cm^2$ fluence) and 5HP (at $5 \times 10^{13} p/cm^2$ fluence) SiGe technologies. As can be clearly seen, negligible degradation of f_T is observed in the 8HP devices, well within the measurement error of about $\pm 5\%$.

From the measured S-parameters, the dynamic base resistance (r_{bb}) can also be extracted, as shown in Figure 8. Observe that the total base resistance increases slightly as the proton fluence increases above $1 \times 10^{13} p/cm^2$, presumably due to displacement effects in the neutral base region, and the deactivation of boron dopants. A similar trend can be seen in 7HP. This effect is very minor, however, because the base profile is very thin (<30 nm), and very heavily doped (> $1 \times 10^{19} cm^{-3}$), and should not have a significant impact on the maximum oscillation frequency or the broadband noise performance.

The total emitter-to-collector delay time (τ_{EC}) and the total depletion capacitance (C_{total}) can be extracted from the measured cut-off frequency characteristics, and are shown as a function of proton fluence in Figure 9 and Figure 10. Interestingly, we can observe that the total transit time of the 7HP devices monotonically increases (degrades) with fluence, while the 8HP total transit

sit time remains constant with fluence. This is clearly reflected in the change in the peak cut-off frequency of the respective technologies (the 8HP peak f_T does not change, while there is a small but observable decrease in peak f_T in 7HP (refer to Figure 7)). The small base observable increase in base resistance at high fluence coincides with a slight decrease in total depletion capacitance (Figure 10), and is consistent with our claims above that small but finite displacement-induced acceptor de-ionization occurs in the base region of the device.

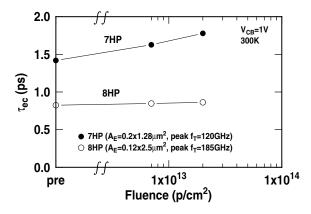


Fig. 9. Extrapolated transit time dependence on proton fluence.

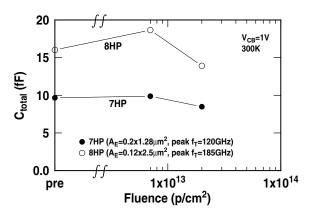


Fig. 10. Total depletion capacitance dependence on proton fluence.

Finally, we have examined the impact of proton exposure on the cut-off frequency characteristics of two different breakdown voltage 8HP transistors on the same wafer (Figure 11). One of the key advantages offered by SiGe technology lies in its ability to trivially integrate transistors with multiple breakdown voltages on the same wafer (using only a collector implant blockout mask), thereby facilitating great flexibility for circuit designers. Clearly, the peak operating frequency does not depend strongly on proton fluence, which is good news. In addition, however, observe that the roll-off in f_T at high J_C does not change significantly with proton exposure. This is significant since the f_T - J_C roll-off is very sensitive to any changes in the effective doping level in the collector region, and thus suggests that collectorregion displacement damage is not a major concern in this technology, consistent with our observations above on base resistance. One can quantify this by plotting the current at which f_T falls by 20%, and normalizing to pre-radiation values (Figure 12). As can be seen, the roll-off current density actually increases slightly with irradiation (more strongly in the low breakdown device).

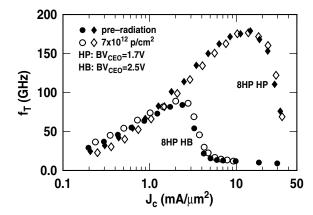


Fig. 11. Pre- and post-radiation cut-off frequency versus collector current density for both high breakdown and low breakdown 8HP SiGe HBTs.

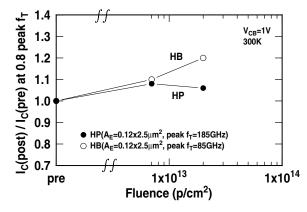


Fig. 12. Normalized collector current roll-off point for both high breakdown and low breakdown 8HP SiGe HBTs.

V. SUMMARY

The impact of proton irradiation on the dc and ac characteristics of third-generation, 185 GHz SiGe HBTs is reported for the first time. The results demonstrate that SiGe HBT technologies can successfully maintain their inherent multi-Mrad total dose hardness, without intentional hardening, even when the device structure is fundamentally altered in order to achieve unprecedented levels of device performance.

VI. ACKNOWLEDGEMENT

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